

# Wednesday 11 June

09:00

#### Session 1 - Defect and Material Characterization

Session | Location: Bucharest | Convener: Dr Ioana Pintilie

09:00-09:05 Workshop opening

Speaker

Dr Ionut Enculescu

09:05-09:10 Workshop opening

**Speakers** 

Dr Ioana Pintilie, Michael Moll

#### 09:10-09:30

Investigation of point and extended defects in electron irradiated silicon dependence on the particle energy

Speaker

Roxana Radu

#### 09:30-09:50

Effect of background impurities and electronic excitation on the behavior of radiation induced interstitial boron complexes

Speaker

Leonid Makarenko

# 09:50-10:10

A<sub>Si</sub>-Si<sub>i</sub> defect as possible origin of electronically activated degradation of boron and indium doped silicon

Speaker

Dr Kevin Lauer

10:10-10:30 Electron Induced Damage in Silicon - TRIM and TCAS Simulations

Speaker

Prof. Gunnar Lindstroem

10:30-11:00 **Coffee** 

### 11:00-11:20

Modelling Vacancy-Interstitial Clusters and their effect on on Carrier Transport in Silicon

Speaker

Dr Ernestas Zasinas

## 11:20-11:40

ESR investigation of paramagnetic point defects in O doped crystalline Si-FZ irradiated with 27 MeV electrons

Speaker

S.V. Nistor

11:40-12:00

High resolution transmission electron microscopy (HRTEM) investigations of silicon irradiated with high energy electrons

Speaker

Leona Nistor

12:00-12:30 Discussion: Defect and Material Characterization

Speaker

Dr Ioana Pintilie

13:00